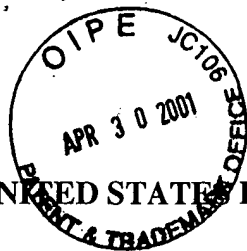


#4



**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Toshiaki AOAI, et al.

Appln. No.: 09/759,362

Group Art Unit: 1741

Confirmation No.: 1920

Examiner: NOT YET ASSIGNED

Filed: January 16, 2001

For: ELECTRON BEAM OR X-RAY NEGATIVE-WORKING RESIST COMPOSITION

**SUBMISSION OF PRIORITY DOCUMENTS**

Commissioner for Patents  
Washington, D.C. 20231

Sir:

Submitted herewith are two (2) certified copies of the priority documents on which claims to priority was made under 35 U.S.C. § 119. The Examiner is respectfully requested to acknowledge receipt of said priority documents.

Respectfully submitted,

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